

Class Y: NEPP Championed Approach to Advanced Package Qualification

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Agenda

- Progress so far
- Background
- Group Interactions
- Why "Class Y"?
- G12 Class Y Task Group Current Status
- Road to QML-Y flight parts procurement
- Summary
- Attachments:
 - Section 1: MIL-PRF-38535, Rev J, Appendix B marked up for Class Y
 - Section 2: MIL-STD-883, Rev H, and MIL-PRF-38535, Rev J
 - Section 3: Developing Packaging for Class Y (credit: Mike Sampson)
 - Section 4: Other Information



Launched June 10, 2011, the Aquarius/SAC-D mission is a partnership between NASA and Argentina's space agency, Comisión Nacional de Actividades Espaciales (CONAE) that will use advanced technologies to make NASA's first space-based measurements of ocean salinity across the globe.

Progress so far

Major milestone last month: G12 approved DLA-VA's kickoff of an Engineering Practice (EP) Study for Class Y.

Background

Back in 2009, there was a big push to bring the Xilinx Viirtex-4 (a non-hermetic part) into the QML system as Class V device. NASA was not in favor as it would have created a massive confusion. Mike Sampson conceived the idea of a new Class Y for non-hermetic space parts to provide QML coverage for Xilinx Virtex-4 and similar devices.

A new G-12 Task Group, TG 2010-01, was formed in early 2010 to address non-hermetic devices for space. Shri Agarwal was asked to lead the effort.

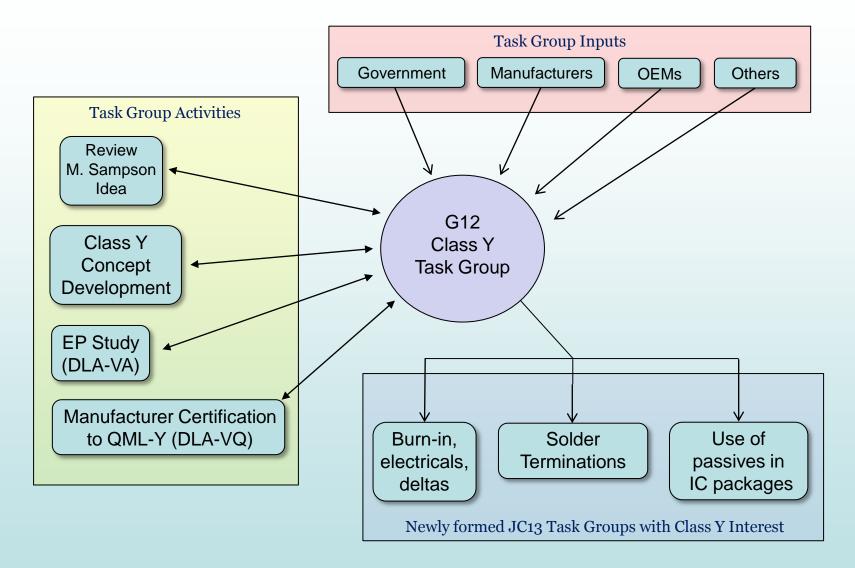
This task was challenging because it:

- Was far more involved than typical G12 tasks,
- Required development of a brand new concept,
- Used system-on-a-chip one of the most complicated devices,
- Needed to be simple and easily understood,
- · Possessed sketchy testing and board assembly boundaries, and
- Was needed to procure a standard QML product as quickly as possible.

Launching in late 2014, SMAP (Soil Moisture Active Passive) will use a combined radiometer and high-resolution radar to measure surface soil moisture and freeze-thaw state, providing new opportunities for scientific advances and societal benefits.



G12 Class Y Task Group Interactions at a Glance

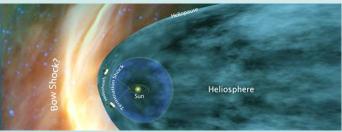


Why "Class Y"?

- This effort is an attempt to bring advancements in packaging technology into the QML system.
- Advancements in packaging technology, increasing functional density and increasing operating frequency have resulted in single die SoCs (System-on-a-Chip) with non-hermetic flip-chip construction, in high-pin-count ceramic column grid array packages
 - "Poster Child" example: Virtex-4 (V-4) FPGAs from Xilinx
 - Such products were evaluated for radiation and reliability and have drawn the attention of the space user community
- Question: How do we bring V-4 and similar microcircuits into the QML system as space products?
 - It can't be Class V because those are non-hermetic devices
 - Our intent is to put V-4 like products for space users in a new category: "Class Y". Section 3 explains electronic packaging, why it's needed and builds the case for Class Y.
 - A year ago, G-12 opened a Task Group to develop Class Y (details on next slide)
- What if we dropped the Class Y effort?

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 It would be a big loss for the space community and the QML program at large because the industry would be limited to ordering via Source Control Drawings (SCDs), which is counterproductive to Mission Assurance, prevents standardization, and is expensive.



The twin Voyager 1 and 2 spacecraft continue exploring where nothing from Earth has flown before. In the 33rd year after their 1977 launches, they each are much farther away from Earth and the Sun than Pluto. Voyager 1 and 2 are now in the "Heliosheath" - the outermost heliosphere layer where the solar wind is slowed by interstellar gas pressure. Both spacecraft still send back scientific information about their surroundings.

G12 Class Y Task Group Current Status

- G-12 Task Group formed in Jan.'10 to develop screening/qualification requirements for non-hermetics for Space (TG2010-01).
- The TG's 4 meetings may be summarized as follows:
 - Average attendance ~ 80
 - As soon as the TG was formed, users were enthusiastic and eager to know when they could procure QML-Y flight parts? See slide 11 on road to procurement.
 - A questionnaire was sent to a targeted group of users, manufacturers and others (There are about 150 names on the Class Y distribution list). The major inputs were:
 - Class Y should cover those items that are ceramic flip-chip non-hermetic construction that have passed the requirements of Appendix B. The broader issue of organic based substrates would be addressed in the next phase of this work. See slide 10 for the TG charter statement.
 - Some respondents asked why should space community even allow use of nonhermetic parts. (Although the feasibility of a hermetic ceramic package with under-fill flip-chip die has been demonstrated, there are sealing process, board level, and other concerns. There are no current development programs as there is no user interest.)
 - Add the word "hermetic" to the definitions of QML-Q and QML-V classes in 38535.
 - NASA does not endorse attaching the description "near hermetic" to Class Y. (How do you quantify "near-hermetic": it could be 10% or 99% hermetic, or less than half, or...?). Both DLA-VA and DLA–VQ support NASA position.

- TG meetings summary (cont'd):
 - Boeing proposed "simplified approach" was adopted:
 - Add paragraph to existing 38535 Appendix B (labeled as Section 1) stating differences for class Y (most remains same as Class V) – see Section 1 attached. One key element in Section 1 is for the manufacturers to submit a Packaging Integration Demonstration Test Plan (PIDTP) to QA for approval. This plan must address issues unique to non-hermetic construction and materials, such as potential materials degradation, interconnect reliability, thermal management, resistance to processing stresses, thermo-mechanical stresses, shelf life, etc. The PIDTP plan shall be approved by QA after consultation with the space community.
 - Separate issues related to non-hermeticity from those related to solder terminations (see below).
 - Provide markups to other affected documents see Section 2 attached.
 - 8 manufacturers have so far expressed interest in offering Class Y products (Xilinx, Actel, Intersil, Aeroflex, BAE, Honeywell, TI, e2v).
 - Government customers and contractors have provided statements of support.
 - Class Y defined as items that are of ceramic, non-hermetic construction.
 - DLA Land and Maritime VA (M. Akbar) was added to the team.
 - Comment from G12 management: The group may be surprised at how quickly this is moving. Most of the time, documents take over a year to get a full draft. You are far ahead of schedule. People just may not realize that this is out of the conceptual stage and into the writing stage.

- Solder terminated parts (could be hermetic or non-hermetic) need attention.
 Proposed a paragraph to add to MIL-PRF-38535, Appendix B (also part of Section 1). The JC-13.2 Task Group on solder terminations has been formed. The broad issues are: solderability, storage and shelf life, electrical testing, reworks, pull test, termination definition (Tin lead solder based?), etc. Some specific questions are:
 - What is the shelf life of the of the CGA? Specifically, how long will these parts be 100% solderable? Is this guaranteed?
 - As the columns would tend to oxidize when exposed to atmosphere, how do you store them: keep in sealed dry bags? Store in dry nitrogen?
 - Do all internal and external portions of the flip-chip package pass MIL-STD-883, Method 5011 (re. evaluation of polymeric materials)?
 - Once assembled, can the finished CGA (Like all other microcircuits, transistors, and hybrids) be functionally tested at -55C, 25C, and +125C? (If the solder melting point is estimated at about 180C, then it would be risky to electrically test the parts at 125C case temperature. Any cold brittle concerns at -55C?)
 - > What board/assembly level test have been run for temp cycling/vibration, etc
 - > What is the max number of allowable column reworks for space products?
 - Specify column pull test
 - Inspection of CGAs (area arrays, in general)
 - Need application notes on CGAs after column attach so that the users know what they are getting, any temperature limitations, adequacy of visual inspection, cleanliness, fluxes to avoid, etc.
 - Coordination with IPC what are the boundaries that separate JEDEC work from IPC?

- Clarification needed on burn-in, electricals and delta requirements. This is a big issue for all microcircuits and would apply to Class Y products as well. For instance, statements such as, the V-4 has undergone 4000 hours of life test with parts biased in a static condition, make you wonder why an FPGA which is basically a digital part was not subjected to a dynamic condition? There are other questions related to the activation energy, low temperature burn-in, etc. At the request of L. Harzstark and S. Agarwal, a JC13 Task Group has been formed to clarify/update requirements in MIL-STD-883, Method 5004.
- The screening/qual requirements for signal conditioning capacitors should be clearly stated – ref. MIL-PRF-38535, Paras 3.15 and 3.15.1. What is the attached method of the BME capacitors used in many designs? During the G12 we heard couple of companies say they use epoxy or silver glass die attachment material to adhere the capacitor to the internal portion of the IC package. There are others who only use solder attachment. A JC13 Task Group has been formed to address these issues.
- What is a space flight part?
 - Land Grid Array, LGA, configuration (yes)
 - Column Grid Array, CGA, configuration (debatable)
- Will the set of 38535 classes, with Class Y added, cover microcircuits for the next several years? (yes, per the poll taken of major manufacturers)



The NASA/ESA/ASI Cassini-Huygens mission has directly sampled the water plumes jetting into space from Saturn's moon Enceladus. The findings from these fly-thrus are the strongest evidence yet for the existence of large-scale saltwater reservoirs beneath the moon's icy crust.

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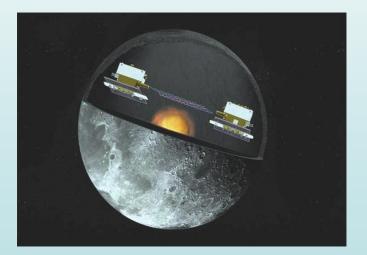
- The Team requested G12 approval for DLA Land and Maritime VA to conduct an Engineering Practice (EP) study using the detailed requirement input the Task Group has developed (Sections 1 & 2 attached). This request was approved by G12.
- The Team's request for clear approval of Task Group charter was also approved by G12. The charter statement reads:
 - "This task group will develop requirements, including qualification and screening standards, for non-hermetic, ceramic-based microcircuits suitable for space applications. Initial effort will be focused on support for devices using flip-chip ceramic column grid array packaging, with resulting requirements to be submitted as a proposal for consideration to DLA Land and Maritime."



NuSTAR (Nuclear Spectroscopic Telescope Array) will be the first focusing high energy X-ray mission, opening up the hard X-ray sky for sensitive study. NuSTAR will search for black holes, map supernova explosions, and study the most extreme active galaxies.

Road to QML-Y Flight Parts Procurement

- Major Milestones:
 - ☑ G12 approval of TG charter
 - ☑ G-12 Class Y Task Group to develop requirements
 - ☑ G12 approval for DLA-VA to commence EP study
 - □ DLA-VA to Conduct EP study and the Class Y Team to resolve issues
 - □ DLA-VA to add Class Y requirements into 38535 and 883
 - □ DLA-VQ to audit suppliers to Class Y requirements
 - Users to procure QML-Y flight parts from certified suppliers



Gravity Recovery and Interior Laboratory (GRAIL) mission, using twin spacecraft flying in formation to investigate the moon's gravity field, a possible inner core and how Earth and other rocky planets formed, launches in late 2011.

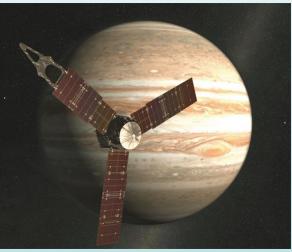
The Team

The Team members are:

- Muhammad Akbar, DLA-VA
- Larry Harzstark, Aerospace
- David Sunderland, Boeing
- Shri Agarwal, NASA/JPL
- Tom Wilson, NASA/JPL

Team resources include:

- Mike Sampson, NASA/GSFC
- Mark Porter, G12
- Brent Rhoton, JC13
- Anduin Touw, G12
- Mike Adams, DLA-VQ
- Rob Heber, DLA-VA
- Tom Hess, DLA-VA
- Charles Saffle, DLA-VA



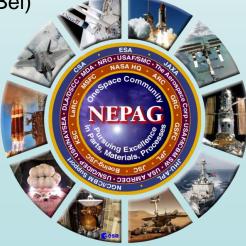
Launching in August 2011, the solar-powered Juno spacecraft enters a low, elliptical orbit circling Jupiter from pole to pole to investigate secrets hidden beneath the planet's thick, colorful clouds. The innovative orbit will avoid lethal belts of charged particles surrounding Jupiter like the less dense Van Allen belts encircling Earth.

NEPAG Contribution to MIL-STD

- Military standards for microcircuits haven't kept pace with developments in packaging technology
 - RADC (Rome Air Development Center) used to be the technical arm of DLA (Defense Logistic Agency) and they did necessary evaluations to keep up with new developments.
- NEPAG (NASA EEE Parts Assurance Group), which is like a large component engineering group representing the government, is addressing some of the issues:
 - 38535 Appendix H, new technology evaluation, update (L. Harzstark).
 - Requirement for screening of passive elements was added to 38535.
 - An out-of-box approach, Class Y, taken for non-hermetic parts (M. Sampson)
 - Support to Counterfeit, PEMs and other JC13/G12 efforts
 - Supporting new JC13 Task Groups: passives, solder term., screening.
 - Support to 13.4: power MOSFETs, other (K. LaBel)

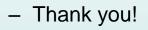
Some NEPAG Activities:

- Weekly Telecons
- Supplier Audits
- DLA Land & Maritime SMD reviews
- Others



In Summary..

- G12 approval for DLA-VA to kick-off an EP study on Class Y marked the completion of a major milestone for the Class Y initiative.
- During the Class Y meetings issues came up and the G12 and JC13 participants and their managements were very helpful suggesting we appoint 3 additional JC13 committees to address them. Their support is appreciated.
- Progress reports will be made in future meetings. The work is ongoing and far from over.
- NEPP is making every effort to strengthen the MIL system and thereby support the flight projects





NASA's Mars Science Laboratory Curiosity rover, a mobile robot for investigating Mars' past or present ability to sustain microbial life, is being tested in preparation for launch this fall.

Section 1

MIL-PRF-38535, Rev J Appendix B marked up for Class Y

Proposed Additions to Appendix B

B.5 Non-Hermetic Space Level Microcircuits – Class Y. This section presents the requirements that are to be used to supplement this specification for non-hermetic ceramic based space level microcircuits, hereinafter referred to as Class Y. Requirements for Class Y products with solder terminations e.g. ball grid array (BGA) or column grid array (CGA) packages, are covered under Para B.6 herein. Class Y microcircuits must obey all previous provisions of Appendix B, except as follows:

B.5.1 Part of identifying number (PIN). Each Y level QML microcircuit shall be marked with the device Class designator "Y" in place of the "V" designator in the PIN format, see 3.6.2a in the main body of this document.

B.5.2 Class Y Assembly Material: For flip chip assembly, solder bump material content shall be specified on device SMD. For non-flip-chip assembly, the standard wire bond assembly requirements govern.

B.5.3 Shelf Life Caution. Sealed dry packs and/or storage in dry nitrogen environment shall be required for class Y devices where the non-hermetic nature of Class Y devices would expose the under-fill and/or thermal grease/epoxy to atmosphere moisture. A moisture sensitivity level (MSL) sticker shall be attached on the dry packs.

B.5.4 Use of Passive Parts to Enhance Performance of Die. Chip capacitors used for Class Y devices must follow requirement specified in paragraph 3.15 and 3.15.1 for space products.

Proposed Additions to Appendix B

B.5 Non-Hermetic Space Level Microcircuits – Class Y (Cont'd)

B.5.5 Screening. For Class Y, the following exceptions apply to the screening tests specified in the main body of this specification and *earlier in* this Appendix.

a. Nondestructive bond pull (NDBP) does not apply to flip-chip devices.

- b. Particle impact noise detection (PIND) does not apply to devices without a cavity.
- c. Seal test (TM1014) is not required.

d. Confocal scanning acoustic microscopy (CSAM) may be substituted for radiographic inspection on approval by QA.

d.1. CSAM tests on the flip chip underfill of each device shall be done per TM2030.

d.2. When heat sink and/or lid is attached to the class Y device, CSAM as above shall also be used when epoxy or thermal grease are used to attach the heat sink and/or lid directly to the back side of the flip chip die.

Proposed Additions to Appendix B

B.5 Non-Hermetic Space Level Microcircuits – Class Y (Cont'd)

B.5.6 Technology Conformance Inspection (TCI). For Class Y, the following exceptions apply to the TCI tests specified in the main body of this specification and earlier in this Appendix.

a.Group A. No exceptions.

b.Group B. Exceptions and additional requirements are as follows: (i) Subgroup 1. Resistance to solvents is not required for laser marked devices (no ink mark on devices). (ii) Subgroup 2. Bond pull test is not required for flip chip assembly. Die shear test or stud pull shall be replaced with assembly in-line flip-chip pull-off test per TM2031, this test shall be done prior to under fill dispense. (iii) Class Y package with lid/heat sink attached on the back side of the flip chip die shall require **the** lid shear or lid torque test. Manufacturers shall submit test procedures for approval by QA for lid shear test. Lid Torque test may follow TM2024 methodology.

c.Group C. No exceptions.

d.Group D. Exceptions and additional requirements are as follows: (i) Seal test (TM1014) and internal water vapor (TM1018) are not required. (ii) Lid torque (TM2024) is optional (?) for devices with lid or heat sink attached to the backside of the flip chip die. (iii) Manufacturers are responsible for ensuring the package meets all appropriate Group D tests as defined in MIL-STD-883, TM5005. For Class Y, a Packaging Integration Demonstration Test Plan (PIDTP) shall be submitted to QA for approval. This plan must address issues unique to non-hermetic construction and materials, such as potential materials degradation (e.g. out-gassing – see MIL-STD-883 TM5011 and moisture absorption), resistance of active devices, passive devices, interconnect and passivation to environment (e.g. moisture, hydrogen or other contaminants), resistance to processing stresses and shelf life. The PIDTP plan shall be approved by QA after consultation with the space community. Following demonstrations shall be included as a minimum: (a) Moisture sensitivity level characterization for exposed flip chip under-fill and/or thermal grease/epoxy (ref: JEDEC J-STD-020D). (b) Flip chip under-fill qualification (Ref: MIL-STD-883, TM5011).

Proposed Additions to Appendix B Cont'd

B.6 Solder-Terminated Microcircuits. This section presents the requirements that are to be used to supplement this specification and the other applicable appendices for space level microcircuits with solder terminations (e.g. Ball Grid Array – BGA or Column Grid Array – CGA). Solder terminated microcircuits just obey all previous provisions of Appendix B (including those of Para B.5 as applicable), except as follows:

B.6.1 Assembly Material: The material contents for solder balls and solder columns shall also be specified on device SMDs.

B.6.2 Shelf Life Caution: The solder ball/columns oxidize when exposed to atmosphere. It is estimated that sealed dry pack may prevent solder from oxidizing for about 2 years. Storage in dry nitrogen is recommended.

B.6.3 Screening. For solder-terminated microcircuits, the following exceptions apply to the screening tests specified in the main body of this specification and carlier in the this Appendix:

a. All required screening steps (including electrical test and burn-in) shall-may be performed prior to attachment of solder balls or columns on approval of QA. If this is done, following ball/column attachment: (a) perform electrical tests over operating temperature range shall be performed, but may be limited to a single temperature to limit damage to the solder terminations, and . Any exceptions shall be approved by QA. (b) visual inspection shall be performed according to TM 2009 of MIL-STD-883 (section 3.3.6).

Proposed Additions to Appendix B Cont'd

B.6.4 Technology Conformance Inspection (TCI). All required TCI tests shall be performed prior to the attachment of solder balls and solder columns to the package substrates. The following exceptions apply to the TCI tests specified in the main body of this specification and earlier in this Appendix.

a. Group B. Exceptions and additional requirements are as follows: Solderability test is not required for BGA and CGA packages. Solderability test has been verified during solder ball and solder column attachment processes. Each BGA ball attachment lot shall have ball shear test (ref: JESD22-B117) or ball pull test (Ref: JESD22-B115) done. (vi) Each CGA column attachment lot shall have column pull or shear test done.

b. Group D. Lead integrity (TM2004) and Adhesion of lead finish (TM2025) are not required for BGA and CGA packages. A Packaging Integrity Demonstration Test Plan (PIDTP) shall be submitted to QA for approval. This plan must address issues unique to solder terminations, such as ball/column integrity, attachment integrity, damage due to test, protection for shipment and shelf life. The PIDTP plan shall be approved by QA after consultation with the space community. For BGA and CGA packages, board level reliability shall be demonstrated. IPC-9071 may be used as a guideline for the test requirement. Note that IPC-9071 preferred test condition, 0C to 100C, may not be sufficient to meet space level.

Need to add requirements for process control, rework of BGA/CGA and qualification

Section 2

MIL-STD-883, Rev H, and MIL-PRF-38535, Rev J (except Appendix B updates for Class Y)

Other Proposed Changes 883

MIL-STD-883H 26 February 2010 METHOD 2009.10 EXTERNAL VISUAL

1. PURPOSE. The purpose of this test method is to verify the workmanship of hermetically packaged hermetic and ceramic-based non-hermetic devices. This test method shall also be utilized to inspect for damage due to handling, assembly, and/or test of the packaged device. This examination is normally employed at outgoing inspection within the device manufacturers facility, or as an incoming inspection of the assembled device. (Page 1)

3.1.21 Class level B and class level S. 2 class levels are used in this document to define requirements for high reliability military applications (Class level B) and space applications (Class level S). Class level B requirements contained in this document are intended for use for Class Q, Class H, and Class M products, as well as Class B M38510 JAN slash sheet product. Class level B requirements are also intended for use for product claimed as 883 compliant or 1.2.1 compliant for high reliability military applications. Class level S requirements contained in this document are intended for use for **Class Y**, Class K, as well as M38510 Class S JAN slash sheet product. Class level S requirements are also intended for use for **Class Y**, Class K, as well as M38510 Class S JAN slash sheet product. Class level S requirements are also intended for use for product claimed as 883 compliant of use for product claimed as 883 compliant for use for Product claimed as 883 compliant of 1.2.1 compliant for use for Product claimed as 883 compliant of use for product claimed as 883 compliant of use for product claimed as 883 compliant of 1.2.1 compliant for use for Product claimed as 883 compliant of 1.2.1 compliant for use for Product claimed as 883 compliant or 1.2.1 compliant for use for Product claimed as 883 compliant or 1.2.1 compliant for use for Product claimed as 883 compliant or 1.2.1 compliant for use for Product claimed as 883 compliant or 1.2.1 compliant for use for Product claimed as 883 compliant or 1.2.1 compliant for space level applications. (Main Body, Page 8)

Other Proposed Changes 38535 J

3.4.2.1 Qualification extension. When a basic plant desires to qualify a device or process flow that includes an offshore site, application for certification and qualification may be extended with QA approval under the following conditions:

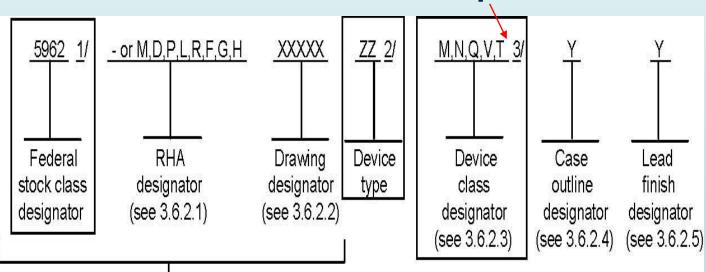
a. Control and approval of the design, fab, assembly and test operations by the manufacturer's TRB is required along with periodic self-assessments of the offshore sites. The manufacturer's TRB shall review all screening and TCI tests to determine whether they should be performed exclusively in the offshore site or reserved for the basic plant in order to assure quality and reliability. The manufacturer's TRB assessment shall be made available to the QA for review or approval as appropriate.

b. QA certification of the offshore site is required. For class Q, Y and V products all operations, sites, and plants shall be QA certified however, this certification may be issued through the manufacturer's TRB with QA approval. Validation of these offshore operations is also required. For assembly site(s) an initial site shall be certified and qualified by the QA. Additional assembly sites shall be assessed subsequent to the initial validation. (Main Body Page 9)

SMD Number

3.6.2 Part Identification Number (PIN). Each QML microcircuit shall be marked with the complete PIN. The PIN may be marked on more than one line provided the PIN is continuous except where it "breaks" from one line to another. As of revision B of MIL-PRF-38535, several types of documents are acceptable for use when specifying QML microcircuits. They are MIL-M-38510 device specifications and SMD. The PIN marked on those parts under QML shall be the same as when supplied by the manufacturer prior to being listed on the QML-38535. The "Q" or "QML" designator combined with the listing of that PIN on a particular vendors QML listing shall indicate the fact that the manufacturer of the device is QML certified and qualified for the processes used to build that product. The PIN system shall be of one of the following forms, as applicable to the SMD or MIL-M-38510 device specification: (Main Body, Page 12)

a. SMD PINs shall be as follows



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3.6.8 <u>QML marked product</u>. For QML certified and qualified manufacturers and manufacturers who have been granted transitional certification (see H.3.3), standard product (Joint Army Navy (JAN), class M SMDs, and military temperature range class B data book product), produced on a QML flow may be marked with the "Q" or "QML" certification mark. This allowance applies to contractor prepared drawings covering standard product only if the drawing was released prior to 31 December 1993 or the date the manufacturer becomes QML whichever is the later date, and the part is marked with the standard part number. A list of the manufacturer's military temperature range product to be included under QML shall be submitted to the QA for approval. Contractor prepared drawings written for nonstandard parts may not be marked with a "Q" or "QML". The only exception to this requirement is an altered item drawing required by a device specification or SMD.

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Only parts covered by a MIL-M-38510 device specification, an SMD, or generic parts that have been grandfathered (a list of eligible devices shall be submitted to DSCC-VA or DSCC-VQ for review) shall be listed on QML-38535. After 31 December 93, new QML products, which are marked with a "Q" or "QML" certification mark, shall be documented on an SMD (see **3.5**). Any device that is not processed in compliance with the provisions of MIL-PRF-38535 shall not be claimed to be compliant. Non-compliant products shall not contain "QML", "QMLY", "QMLV" or any variant thereof within the vendor part number or within any marking located on the package. (Main Body, Page 15)

4.3 Technology conformance inspection (TCI). All product shipped shall be capable of passing TCI in accordance with tables II, III, IV, and V; for plastic packages see Table IB herein. With QA approval when TM 5005 of MIL-STD-883 is used as a TCI option, class Q shall be capable of passing the class level B flow and class V shall be capable of passing the class level S flow. **Class Y shall be capable of passing the flow as defined in Appendix B**. When selecting the TM 5005 TCI option for class V, the group B end-point electricals shall be the same as the group C end-point electricals, unless otherwise specified in the acquisition document. TCI testing shall be accomplished by the manufacturer on a periodic basis to assure that the manufacturer's quality, reliability, and performance capabilities meet the requirements of the QM plan (see G.3.3). Where appropriate, as an option, in place of the fixed sample size (Acceptance number) the manufacturer may use the sample size series (SSS) plan of Appendix D. (Main Body, Page 17).

6.4.28 <u>Class N</u>. Items which have been subjected to and passed all applicable requirements of this specification including qualification testing, screening testing, and TCI/QCI inspections, and are encapsulated in plastic. This product must be assessed by the user to determine if it is appropriate for use in users' application.

6.4.29 Class Q. Items which **are hermetic and** have been subjected to and passed all applicable requirements of this specification and applicable appendices including qualification testing, screening testing, and TCI/QCI inspections.

6.4.30 Class V. Items that **are hermetic and** meet all the class Q requirements, and have been subjected to, and passed all applicable requirements of appendix B herein.

6.4.31 Class Y. Items that are ceramic based non-hermetic , and have been subjected to, and passed all applicable requirements refinements of Appendix B herein (see B.5).

6.4.32 Class B.
6.4.33 <u>Class S</u> .
6.4.34 <u>Class T</u> .
6.4.35 Qualified manufacturer's line.
6.4.36 Test optimization.
6.4.37 Audit team.
6.4.38 Class level B.
6.4.39 Class level S.
6.4.46 Storage Temperature.

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Paragraph numbers only were changed.

A.3.5 <u>Design and construction</u>. Microcircuit design and construction shall be in accordance with all the requirements specified herein and in the device specification or drawing.

A.3.5.1 Package. All devices supplied under this appendix **except for Class Y** shall be hermetically sealed in glass, metal, or ceramic (or combinations of these) packages. No organic or polymeric materials (lacquers, varnishes, coatings, adhesives, greases, etc.) shall be used inside the microcircuit package unless specifically detailed in the device specification or drawing (e.g., polyimide interlayer dielectric). Alpha Particle protection is permitted if permitted by the device specification or drawing. Desiccants may be used in the microcircuit package (except for class level S devices where they are prohibited) only if each lot is subjected to and passes an internal water vapor test, test method 1018 of MIL-STD-883, with a limit of 1,000 ppm at +100 C for a sample of 3(0) or 5(1). The internal moisture content for class level S devices, after completion of all screening, shall not exceed 5,000 ppm at +100 C. Polymer impregnations (backfill, docking, coating, or other uses of organic or polymeric materials to effect, improve, or repair the seal) of the microcircuit package shall not be permitted. Polymer coating used to effect or improve marking adhesion shall not be applied over lid seal area. (Main Body, Page 48)

Need to define package for Class Y

A.3.5.6.2 Lead or terminal material. Lead or terminal material shall conform to one of the following compositions:

a. Type A: Iron-nickel-cobalt alloy: SAE-AMS-I-23011, class I, ASTM F15.

b. Type B: Iron-nickel alloy (41 percent nickel): SAE-AMS-I-23011, class 5, ASTM F30.

c. Type C: Co-fired metallization such as nominally pure tungsten. The composition and application processing of these materials shall be subject to QA approval and submitted with application to test and as otherwise requested by the QA.

d. Type D: Copper-core, iron-nickel ASTM F30 alloy (50.5 percent nickel). The core material shall and the consist of copper (oxygen-free), ASTM B170, grade 2.

e. Type E: Copper-core ASTM F15 alloy. The core material shall consist of copper (oxygen-free) ASTM B170, grade 2.

f. Type F: Copper (oxygen-free) ASTM B170, grade 2. This material shall not be used as an element of any glass-to-metal seal structure.

g. Type G: Iron-nickel alloy (50.5 percent nickel): SAE-AMS-I-23011, class 2, ASTM F30.

h. Type H: Tin-lead alloy solder balls or columns.

A.3.5.6.3 Microcircuit finishes. Finishes of all external leads or terminals and all external metal package elements shall conform to either A.3.5.6.3.2 or A.3.5.6.3.3, as applicable. The use of pure tin, as an underplate or final finish, is prohibited both internally and externally. The tin content of solder shall not exceed 97 percent. Tin shall be alloyed with a minimum of 3 percent lead by weight. The lead finish designator (see A.3.6.2.7) shall apply to the finish of the leads or terminals. The leads or terminals shall meet the applicable solderability and corrosion resistance requirements. The other external metallic package elements (including metallized ceramic elements) shall meet the applicable corrosion resistance requirements. Finishes on interior elements (e.g. bonding pads, posts, tabs) shall be such that they meet the lead bonding requirements and applicable design and construction requirements. The use of strike plates is permissible to the maximum thickness of 10 microinches (0.25 micrometer). All plating of finishes and undercoats shall be deposited on clean, non-oxidized metal surfaces. Suitable deoxidation or cleaning operations shall be performed before or between plating processes. All parts shall be capable of meeting the following requirements of MIL-STD-883, as applicable. (Appendix A, Page 54.)

Section 3

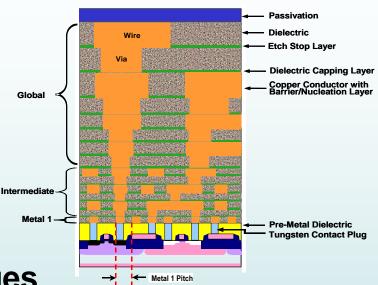
Developing Packaging for Class Y *

NEPAG

* Courtesy of Mike Sampson

Outline

- What is Electronic Packaging?
- Why Package Electronic Parts?
- Evolution of Packaging
- New Application Challenges and Solutions
- Associated Assurance Challenges
- The Class Y Concept and Possible Extensions
- Embedded Technologies
- NEPP Activities

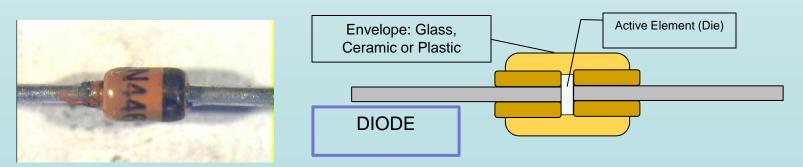


What is Electronic Packaging?

- Electronic "Packaging" can have two basic meanings:
 - First (Part) Level: The "envelope" of protection surrounding an active electronic element, and also the termination system to connect it to the outside world
 - Second and Higher Levels: The assembly of parts to boards, boards to slices, slices to boxes, boxes to systems, instruments and spacecraft
- This discussion covers examples of both

Why Package Electronic Parts?

- To protect the active element against:
 - Handling
 - Shock and vibration
 - Contamination
 - Light penetration or emission
- To provide a suitable system to make connection between the element and the printed wiring board
- To prevent conductive parts of the element from coming in contact with other conductive surfaces, unless intended

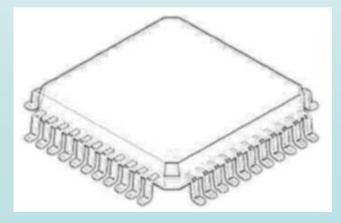


Package Options – Hermetic?

- Once, hermetic packages were the preferred option
- Now, few hermetic options for latest package technologies
 - Development of new hermetic options unattractive
 - Very high Non Recurring Expenses
 - Very high technical difficulty
 - Very low volume
 - Demanding customers
- Market is driven by consumer products
 - Low cost
 - High volume
 - Rapid turnover = Non hermetic, mostly plastic
 - "Green"
 - Minimized size
- New hermetic technologies may become available but timing is uncertain

The "General" Package

- Typically, packages consist of the same basic features but achieve them in many ways:
 - Functional elements active die, passives etc.
 - Interconnects between elements (2 or more elements)
 - A substrate
 - Interconnects to the external I/O of the package
 - A protective package
 - Interconnects to the next higher level of assembly



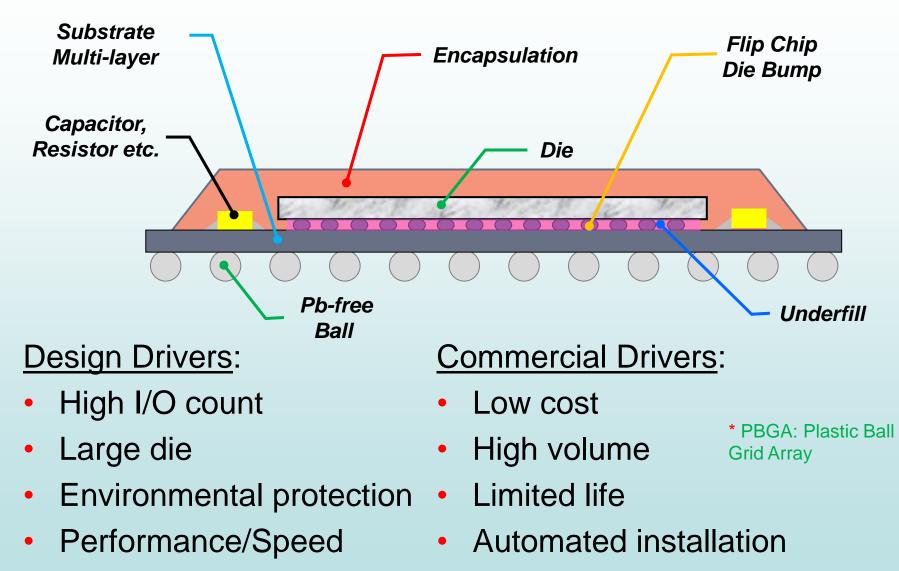
Continuous Packaging Challenges

- I/O s, increasing number, decreasing pitch
- Heat Dissipation, (especially in space)
- Manufacturability
- Materials
- Mechanical
- Installation
- Testability
- Inspectability
- RoHS (Pb-free)
- (Space Environment)



Lunar Reconnaissance Orbiter (LRO), Built at GSFC, Launched with LCROSS, June 18,2009

Commercial, Non-hermetic Package (PBGA*)



Compact

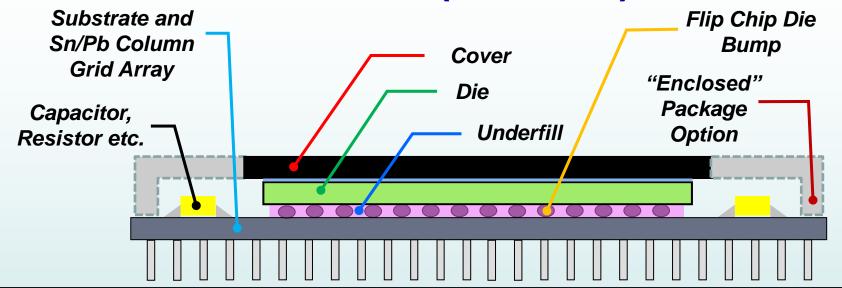
Ancillary parts

Space Challenges for Complex Non-hermetic Packages

- Vacuum:
 - Outgassing, offgassing, property deterioration
- Foreign Object Debris (FOD)
 - From the package threat to the system, or a threat to the package
- Shock and vibration
 - During launch, deployments and operation
- Thermal cycling
 - Usually small range; high number of cycles in Low Earth Orbit (LEO)
- Thermal management
 - Only conduction and radiation transfer heat
- Thousands of interconnects
 - Opportunities for opens, intermittent possibly latent
- Low volume assembly
 - Limited automation, lots of rework
- Long life
 - Costs for space are high, make the most of the investment
- Novel hardware
 - Lots of "one offs"
- Rigorous test and inspection
 - To try to find the latent threats to reliability

ONE STRIKE AND YOU'RE OUT!

Non-hermetic Package, With"Space" Features (CCGA*?)



Space Challenge	Some Defenses		
Vacuum	Low out/off-gassing materials. Ceramics vs polymers.		
Shock and vibration	Compliant / robust interconnects - wire bonds, solder balls, columns, conductive polymer		
Thermal cycling	Compliant/robust interconnects, matched thermal expansion coefficients		
Thermal management	Heat spreader in the lid and/or substrate, thermally conductive materials		
Thousands of interconnects	Process control, planarity, solderability, substrate design		
Low volume assembly	Remains a challenge		
Long life	Good design, materials, parts and process control		
Novel hardware	Test, test	* Ceramic Column Grid Array	
Rigorous test and inspection	Testability and inspectability will always be challenges	Charmay	40

Hermeticity

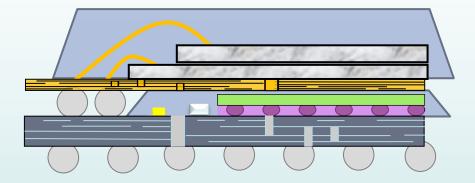
- NASA prefers hermetic packages for critical applications
- Hermeticity is measureable, assuring package integrity
- Only 3 tests provide assurance for hermetic package integrity:
 - Hermeticity nothing bad can get in
 - Residual or Internal gas analysis nothing bad is inside
 - Particle Impact Noise Detection no FOD inside
- NON-HERMETIC PACKAGE INTEGRITY IS HARD TO ASSESS - NO <u>3 BASIC TESTS</u>
- Non-hermetic packages expose materials' interfaces that are locked away in hermetic ones

But What is Hermetic?

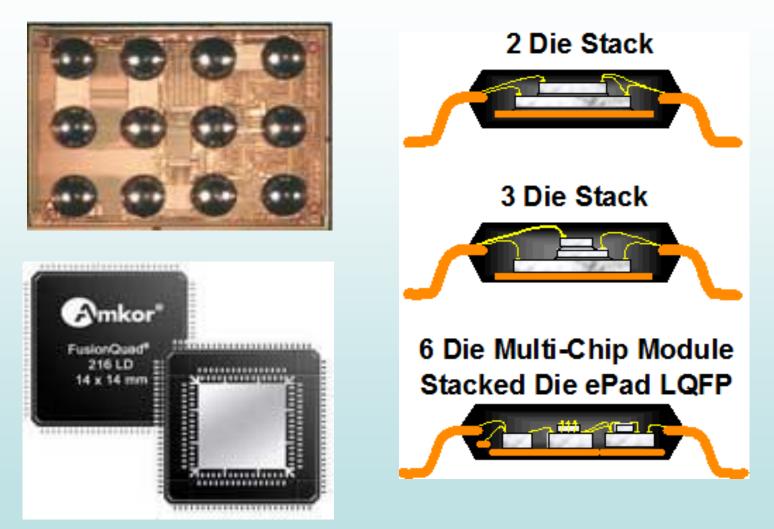
- Per MIL-PRF-38534 Appx E and 38535 Appx A, hermetic packages must consist of metals, ceramic and glass in combinations ONLY, no polymerics
- Meets aggressive leak rate test limits
 - Verifies low rate of gas escape/ atmospheric interchange
 - Even so, small volume packages meeting "tight limits" theoretically exchange their atmosphere very quickly:
 - 0.001 cc, exchanges 93% in 1 month at 5X10⁻⁸ atmosphere/cc/sec!
 - 1.0cc, 96% in 10 years at 1 X 10⁻⁸
 - Even large packages with quite small leaks can surprise
 - 10 cc, 96% in 1 year at 1 X 10⁻⁶ !
- For applications in space vacuum why care?
 - Risk for contamination on the ground
 - Risk for outgassing in vacuum

Non-hermetic Package Variations

- Current and future package options mix and match elements in almost infinite combinations
- Elements include:
 - Wire bonds
 - Ball interconnects
 - Solder joints
 - Conductive epoxies
 - Vias
 - Multi-layer substrates
 - Multiple chips, active and passive (hybrid?)
 - Stacking of components
 - Embedded actives and passives
 - Polymers
 - Ceramics
 - Enclosures/encapsulants
 - Thermal control features



Some Large Device Package Options



From Amkor's Website http://www.amkor.com/go/packaging

More Complexity is Coming

- Stacking of chips to provide a third dimension of density and complexity
 - Stacking of Field Programmable Gate Arrays (FPGAs) appears imminent
 - Stacking of memory die is "old hat"
 - Through-silicon vias instead of bond wires
 - Maintain speed and allow lots of I/Os
 - High volumetric efficiency
 - Significant manufacturability challenges
 - Material and dimensional interfaces
 - Testability
 - Significant usability challenges
 - Design complexity
 - Handling, testing, rework/replace, risk management
 - Cost versus benefit trades

MIL-PRF-38535, Class Y

- "Y Not" Non-hermetic for Space?
- Proposed new class for M38535, monolithic microcircuits
- Class Y will be for Space level non-hermetic
- Class V will be defined as hermetic only
- Addition to Appendix B, "Space Application"
- Package-specific "integrity" test requirements proposed by manufacturer, approved by DLA* and government space
- The Package Integrity Test Plan must address:
 - Potential materials degradation
 - Interconnect reliability
 - Thermal management
 - Resistance to processing stresses
 - Thermo-mechanical stresses
- G12 Task Group established 01/13/10



NEPP Activities

- Continuous surveillance of emerging trends
- Have evaluated embedded passives
 - Partnering with Navy Crane
 - Quite mature technologies, bulk capacitive layer
 - Works but "space" low quantities a challenge
- Have tried to evaluate a novel, flexible, embedded active-die technology
 - Considerable promise
 - Beset by technical problems, particularly die thinning
 - Consider revisiting as technology improves
- Initial evaluations of technical readiness of die thinning, through-hole vias and advance die stacking are needed
- Continue development of Class Y concept

Section 4

Other Information

MIL-PRF38535 Class Definitions

Ref: MIL-PRF-38535, Rev J

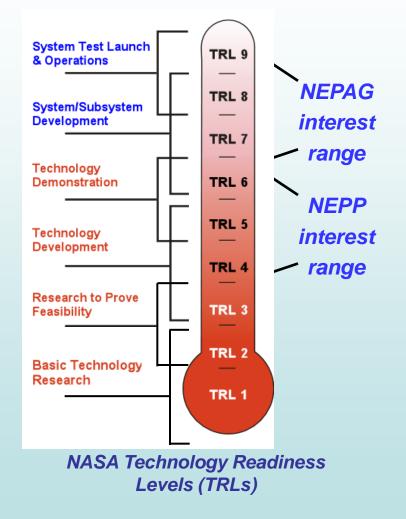
Para 6.4.28 Class N. Items which have been subjected to and passed all applicable requirements of this specification including qualification testing, screening testing, and TCI/QCI inspections, and are encapsulated in plastic. This product must be assessed by the user to determine if it is appropriate for use in users' application.

Para 6.4.29 Class Q. Items (add "that are hermetic and") which have been subjected to and passed all applicable requirements of this specification and applicable appendices including qualification testing, screening testing, and TCI/QCI inspections. (Note: The only known exception would be non-hermetic 5962-9760805(thru 09)QYA 32-bit RISC processors.)

Para 6.4.30 Class V. Items that (add "are hermetic and") meet all the class Q requirements, and have been subjected to, and passed all applicable requirements of appendix B herein.

NEPP/NEPAG Mission and Focus

- The NEPP mission is to provide guidance to NASA for the selection and application of microelectronics and other parts technologies, to improve understanding of the risks related to the use of these technologies in the space environment and to ensure that appropriate research is performed to meet NASA mission assurance needs.
- NEPP subset: NASA Electronic Parts Assurance Group (NEPAG)
 - Focuses on daily needs of parts assurance knowledge-base



NEPAG Contribution to MIL-STD

- Military standards for microcircuits haven't kept pace with developments in packaging technology
 - RADC (Rome Air Development Center) and later RAC (Rome Air Center) used to be the technical arm of DLA (Defense Logistic Agency) and they did necessary evaluations to keep up with new developments.
- NEPAG (NASA EEE Parts Assurance Group), which is like a large component engineering group representing space agencies, is addressing these issues:
 - 38535 Appendix H, new technology evaluation, update (L. Harzstark).
 - Requirement for screening of passive elements was added to 38535.
 - An out-of-box approach was taken for non-hermetic parts, e.g., V-4; concept of a new class, "Class Y" (M. Sampson)
 - 3 new JC13 task groups formed 38535.
 - Support to 13.4: power MOSFETs, other (K. LaBel)

Some NEPAG Activities:

- Weekly Telecons
- Supplier Audits
- DLA Land & Maritime SMD reviews
- Others

